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520.37698CX1



**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: K. TAKAHASHI, et al.  
Serial No: 09/414,520  
Filed: October 8, 1999  
Title: A PLASMA PROCESSING APPARATUS AND A PLASMA  
PROCESSING METHOD  
Group: 1763  
Examiner: R. ZERVIGON

**AMENDMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

February 28, 2005

Sir:

In response to the Office Action mailed October 26, 2004, please  
amend the above-identified application as listed in the following, and as set  
forth on the following pages:

Amendments to the Claims; and

Remarks are included following the amendments.